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# A novel method of preparing vanadium-based precursors and their enhancement mechanism in vanadium nitride preparation

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Vanadium nitride is widely used because of its excellent properties. The existing production methods are affected by the problems of complex preparation for the vanadium source, high temperature, and low N content. In this work, a wide range of vanadium solutions were used as the vanadium source to prepare vanadium nitride with high N content. In this work, a novel precursor was prepared by a microwave-assisted precipitation process, and then the vanadium nitride was prepared by reduction and nitridation precursor at 1150 °C. The results show that in the microwave-assisted method, the particle size and structure of the precursor can be adjusted, so that the contact area of the precursor with N<sub>2</sub> during the nitridation process becomes larger, the N<sub>2</sub> diffusion path becomes shorter, and the formation of vanadium nitride is enhanced. The prepared product has a nitrogen content of 17.67 wt% and is composed of uniform spherical particles. The content of other chemical components and density can achieve the standard requirements specified in VN16. Meanwhile, the thermodynamic analysis showed that the NH<sub>3</sub> generated by the thermal decomposition of the precursor can be used directly as a reducing gas to reduce V<sub>2</sub>O<sub>5</sub>, and reduced the emission of polluting gases. It is a feasible method to prepare vanadium nitride by reduction and nitridation.

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## 1 Introduction

Transition metal nitrides are attracting increasing focus owing to their excellent physical and chemical properties.<sup>1–4</sup> Vanadium nitride is widely used in alloy components, coatings, battery materials, supercapacitor materials, and catalytic carriers<sup>5–12</sup> due to its high melting point, excellent wear resistance, high-temperature stability, and excellent electrical conductivity.<sup>13–17</sup> In order to meet the ever-increasing demand for vanadium nitride and the development of high-quality vanadium nitride, new methods to prepare vanadium nitride are becoming increasingly important.

Therefore, how to prepare vanadium nitride efficiently has attracted a lot of attention, and there are several methods

available for the preparation of vanadium nitride. These are ammonolysis sintering,<sup>18,19</sup> carbothermal reduction nitridation,<sup>20,21</sup> mechanochemical synthesis,<sup>22</sup> hydrothermal synthesis,<sup>23</sup> deposition,<sup>24</sup> and magnesium thermal reduction.<sup>25</sup> However, only the carbothermic reduction of vanadium oxide is a method that can accomplish industrial production. It is characterized by co-grounding the vanadium source and reducing agent, and then prepared VN by holding the mixture above 1300–1500 °C for 4–6 h.<sup>26–28</sup> The production of vanadium nitride using vanadium oxide exist many problems, such as high reaction temperature, long reaction time and low N content of vanadium nitride.

Therefore, researchers have improved the preparation process of vanadium nitride to make it more mature with lower temperature, shorter time, higher quality and better performance. Qin used an ultra-fast dissolution method to prepare VO<sub>2</sub> precursor in the form of porous foam, and then the precursor was ammoniated at 700 °C for 2 h to prepare VN.<sup>18</sup> Han reported that precursor containing vanadium source and carbon source was precipitated using vanadium-rich liquid as the vanadium source. Vanadium nitride was prepared by reduction nitride of the precursor at 1150 °C for 1 h, with a N content of 16.38 wt%. Compared with the conventional carbon thermal reduction technique, the reaction temperature can be reduced and the reaction time can be shortened.<sup>29</sup> In addition, Huang used microwave efficient heating to promote the preparation of vanadium nitride, and the N content of the VN was

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12–16 wt%.<sup>30</sup> However, studies on the precursor properties are not common.

In the material preparation process, microwave is used to assisted in the preparation of precursors. The purpose is to reduce the time and improve the comprehensive performance. It was reported that after microwave-assisted in the hydrothermal reaction,  $\text{Ce}(\text{OH})\text{CO}_3$  hexagonal microplate precursor were formed in a short time, and then heating decomposition the precursor can product  $\text{CeO}_2$  powder, which improved the catalytic performance and physicochemical properties of  $\text{CeO}_2$ .<sup>31–33</sup> Liu synthesized zinc layered double hydroxalates (ZnIn-LDHs) precursor by microwave hydrothermal method and prepared zinc layered double oxides (ZnIn-LDOs) by controlled calcination method using precursor. The catalytic properties of the products were improved.<sup>34</sup>

Herein, we investigated the preparation of precursor by microwave-assisted precipitation and their enhancement mechanism on the vanadium nitride production. The thermodynamic behavior related to the precursor decomposition was analyzed. The effects of the precursor prepared by different conditions on vanadium nitride were studied. In addition, the mechanism of the enhanced properties of vanadium nitride prepared after microwave assistance was discussed by analyzing the phase, microstructure and particle size distribution of the precursor.

## 2 Materials and methods

### 2.1 Materials

The vanadium solution used was obtained by blank roasting, acid leaching, and solvent extraction from vanadium shale obtained from Tongshan, Hubei, China. The main chemical composition of the solution is shown in Table 1. Carbon black containing 94.80 wt% of carbon with a particle size of less than  $-0.074$  mm was used as the reducing agent.

### 2.2 Material characterization

Vanadium concentration of the solution was measured through ferrous ammonium sulfate titrimetry.<sup>35</sup>

The nitrogen content (N content) was analyzed and determined by distillation–neutralization titration.

X-ray diffraction (XRD) patterns were performed using a Rigaku D/MAX-RB X-ray diffractometer (Rigaku, Akishima, Japan) with  $\text{Cu K}\alpha$  radiation to analyze the phase compositions in the products.

Microscopic observation and elemental analysis were performed using scanning electron microscopy (JSM-IT300, Jeol, Tokyo, Japan) equipped with X-ACT energy dispersive X-ray attachment (Oxford Instruments, Oxford, UK).

Thermogravimetric analysis (TG) experiments were performed using an STA449C analyzer (Netzsch, Germany), heated

from room temperature to  $1400^\circ\text{C}$  at a heating rate of  $10^\circ\text{C min}^{-1}$ , and a  $\text{N}_2$  flow rate of  $50\text{ mL min}^{-1}$ .

### 2.3 Synthesis of vanadium nitride

The process flow sheet of vanadium nitride preparation is shown in Fig. 1. Typically, vanadium(IV) was oxidized to vanadium(V) by adding an appropriate amount of  $\text{NaClO}_3$  to the vanadium solution. After vanadium(IV) complete oxidation, C was added to the solution and a mixed slurry was obtained. Adjusted the pH of the slurry to 1.9 with ammonia, and then stirred for 30 min in a microwave reactor with a power of 400 W and a temperature of  $90^\circ\text{C}$ . After solid–liquid separation, all precursor were dried. Pressed into a cylindrical block with a diameter of 30 mm under a pressure of 10 KN. Put the cylindrical block into a tubular atmosphere furnace (BTF-1700C, AnHui BEQ Equipment Technology Co., Ltd) with a certain flow rate of nitrogen (99.999 wt%). The sample was calcined at  $550^\circ\text{C}$  for 20 min to remove ammonia and pre-reduction at  $650^\circ\text{C}$  for 120 min, and then heated to the required temperature for reduction and nitridation reaction. Subsequently, the product was cooled to room temperature in a  $\text{N}_2$  atmosphere and taken out for testing.

## 3 Thermodynamic theory of precursor decomposition

In addition to stable  $\text{V}_2\text{O}_5$ ,  $\text{VO}_2$ ,  $\text{V}_2\text{O}_3$ , and  $\text{VO}$ , there are some vanadium oxides in other valence states, such:  $\text{V}_3\text{O}_5$ ,  $\text{V}_3\text{O}_7$ ,  $\text{V}_4\text{O}_9$ , and  $\text{V}_6\text{O}_{13}$  in the V–O system. In this study, thermodynamic analysis showed that the existence state of V in the precursor prepared by microwave-assisted is  $(\text{NH}_4)_2\text{V}_6\text{O}_{16}\cdot 1.5\text{H}_2\text{O}$ .  $(\text{NH}_4)_2\text{V}_6\text{O}_{16}\cdot 1.5\text{H}_2\text{O}$  is heated and decomposed to generate

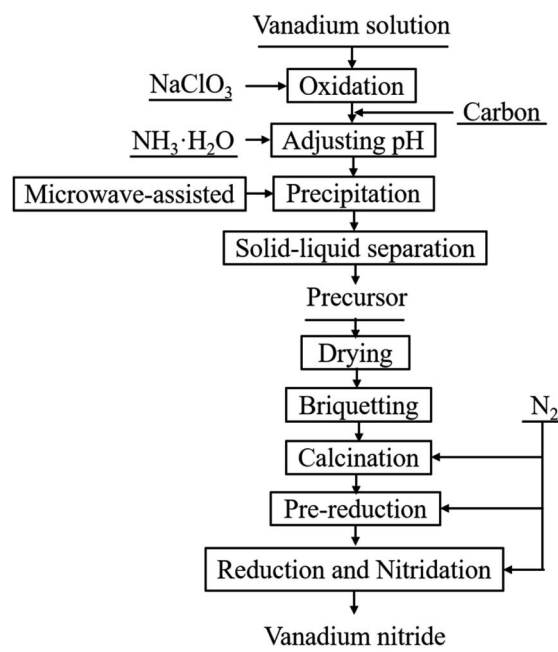


Fig. 1 Process flow sheet for preparation of vanadium nitride.

Table 1 Main chemical composition of the solution ( $\text{g L}^{-1}$ )

Element	V	Al	Fe	Na	K	P
Concentration	25.73	5.78	0.06	0.42	0.34	0.10



$V_2O_5$  and  $NH_3$ . The  $N_2$  in the tube furnace will use a protective atmosphere at low temperature, and  $NH_3$  can reduce vanadium(v) to low-value vanadium. With  $(NH_4)_2V_6O_{16} \cdot 1.5H_2O$  as the vanadium source, the possible reaction equations and corresponding thermodynamic data of the heating deamination process areas in Table 2.

Analyzed the reaction equation according to the corresponding thermodynamic data. Under the standard state, the  $\Delta G^\theta - T$  diagram of the reaction is as Fig. 2. Combined with the calculation in Table 1 and Fig. 2, it can be seen that  $V_2O_5$  is easily reduced to low-valent vanadium oxide by  $NH_3$ , and may be reduced to  $V_2O_4$  and  $V_2O_3$  at room temperature. At higher temperatures,  $V_2O_5$  is reduced to other vanadium compounds. When the temperature is higher than 897 K,  $V_2O_5$  can be reduced to V. When the amount of  $NH_3$  is sufficient,  $V_2O_5$  has been reduced to  $V_2O_3$ , so reactions (11)–(13) will not occur.

According to the research of scholars, the precursor  $(NH_4)_2V_6O_{16} \cdot 1.5H_2O$  can be decomposed at a lower temperature.<sup>36</sup> Under  $N_2$  as a protective atmosphere, low-temperature decomposition produces  $NH_3$ . Due to the limited composition and quality of the raw materials, the generated  $NH_3$  is not enough to reduce it all. That is,  $NH_3$  partially reduces  $V_2O_5$ . Therefore, the vanadium oxides that may be generated through the calcination deamination process are  $V_3O_5$ ,  $V_3O_7$ ,  $V_4O_9$ ,  $V_6O_{13}$ ,  $V_2O_4$ ,  $V_2O_3$ .

## 4 Results and discussion

### 4.1 Effect of main reaction conditions on N content of vanadium nitride

**4.1.1 Effect of precursor preparation conditions on N content of vanadium nitride.** The precursor was reduction and nitridation at a temperature of 1150 °C and a  $N_2$  flow rate of 200 ml min<sup>-1</sup>. The N content was used as a measure to determine the optimal process parameters for the preparation of the precursor. The effects of microwave power, drying time, vanadium precipitation time and stirring speed on the N content of vanadium nitride are shown in Fig. 3.

It is showed that microwave-assisted reaction had great potential in improving efficiency and shortening time, and high

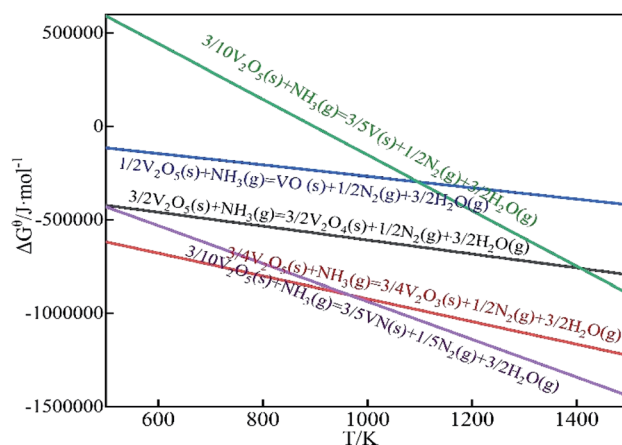


Fig. 2 The  $\Delta G^\theta - T$  diagram of the calcination deamination process.

microwave power was beneficial to selective heating of solution.<sup>37</sup> The enhanced reactivity under microwave heating was in favor of direct carbothermic reduction of ilmenite concentrate with sodium carbonate.<sup>38</sup> Microwave-assisted hydrothermal synthesis of CuO nanostructures is an effective method to improve the gas sensitivity of materials.<sup>39</sup> It can be seen from Fig. 3a that as the microwave power increased, the N content of vanadium nitride products increased and then decreased. When increased from 250 W to 400 W, the nitrogen content increased from 13.85 wt% to 14.95 wt%. This result may be due to the acceleration of precipitation kinetics under microwave radiation. At 600 W, the N content was only 12.08 wt%. After microwave-assisted, the vanadium precipitation rate can reach 99.3 wt%. Considering energy consumption and N content comprehensively, 400 W is determined as the best power for preparing the precursor.

As shown in Fig. 3b, the N content rapidly increased from 13.94 wt% to 17.13 wt% when the precursor drying time increased from 1.5 h to 3.5 h. After 3.5 h, the N content decreased. Drying 1.5 h is very short resulted a mass of water remains on the precursor. As the temperature is increased, the water evaporates and a large number of voids appear in the precursor, with a narrow contact area with  $N_2$  and a lack of

Table 2 Thermodynamics analysis data of calcination deamination process

Number	Reaction	$\Delta G^\theta (T)/J \text{ mol}^{-1}$	T/K
1	$(NH_4)_2V_6O_{16} \cdot 1.5H_2O(s) = 3V_2O_5(s) + 2NH_3(g) + 2.5H_2O(g)$	No $(NH_4)_2V_6O_{16} \cdot 1.5H_2O$ data	—
2	$9/10V_2O_5(s) + NH_3(g) = 3/5V_3O_5(s) + 1/2N_2(g) + 3/2H_2O(g)$	No $V_3O_5$ data	—
3	$9/2V_2O_5(s) + NH_3(g) = 3V_3O_7(s) + 1/2N_2(g) + 3/2H_2O(g)$	No $V_3O_7$ data	—
4	$3V_2O_5(s) + NH_3(g) = 3/2V_4O_9(s) + 1/2N_2(g) + 3H_2O(g)$	No $V_4O_9$ data	—
5	$9/4V_2O_5(s) + NH_3(g) = 3/4V_6O_{13}(s) + 1/2N_2(g) + 3/2H_2O(g)$	No $V_6O_{13}$ data	—
6	$3V_3O_7(s) + NH_3(g) = 3/2V_6O_{13}(s) + 1/2N_2(g) + 3/2H_2O(g)$	No $V_6O_{13}$ and $V_3O_7$ data	—
7	$3/2V_3O_7(s) + NH_3(g) = 9/4V_2O_4(s) + 1/2N_2(g) + 3/2H_2O(g)$	No $V_3O_7$ data	—
8	$2/3V_6O_{13}(s) + NH_3(g) = 2V_2O_4(s) + 1/2N_2(g) + 2/3H_2O(g)$	No $V_6O_{13}$ data	—
9	$3/2V_2O_5(s) + NH_3(g) = 3/2V_2O_4(s) + 1/2N_2(g) + 3/2H_2O(g)$	$\Delta G^\theta = -235\,615.4 - 373.075T$	631
10	$3/4V_2O_5(s) + NH_3(g) = 3/4V_2O_3(s) + 1/2N_2(g) + 3/2H_2O(g)$	$\Delta G^\theta = -314\,037.7 - 609.024T$	516
11	$1/2V_2O_5(s) + NH_3(g) = VO(s) + 1/2N_2(g) + 3/2H_2O(g)$	$\Delta G^\theta = 36\,534.3 - 304.002T$	120
12	$3/10V_2O_5(s) + NH_3(g) = 3/5V(s) + 1/2N_2(g) + 3/2H_2O(g)$	$\Delta G^\theta = 1\,336\,803.0 - 1489.893T$	897
13	$3/10V_2O_5(s) + NH_3(g) = 3/5VN(s) + 1/5N_2(g) + 3/2H_2O(g)$	$\Delta G^\theta = 77\,191.1 - 1014.606T$	76



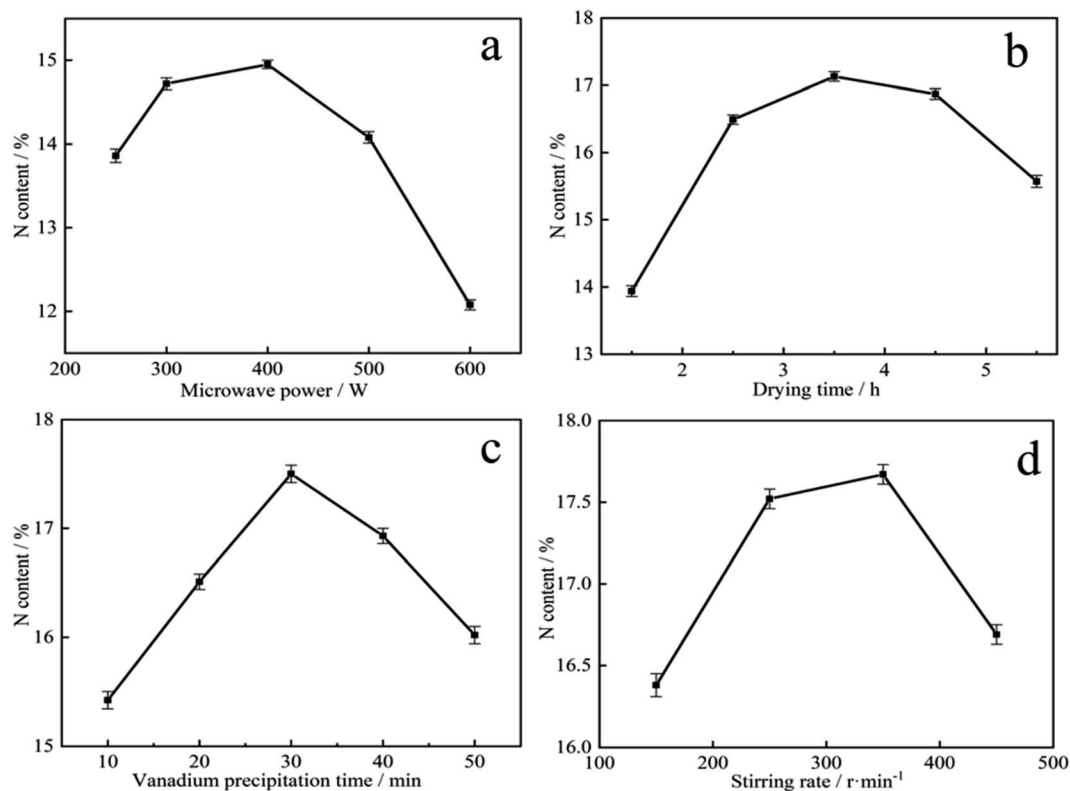


Fig. 3 Effect of precursor preparation conditions on N content of vanadium nitride: (a) microwave power; (b) drying time; (c) vanadium precipitation time; (d) stirring speed.

reaction zone. When the drying time exceeds 3.5 h, there is almost no water in the precursor, and under the same pressure conditions, the material is compacted by the briquettes and  $N_2$  cannot enter the interior, resulting in a very low N content in vanadium nitride. According to Fig. 3c, the precipitation time of vanadium increased, the N content increased first and then decreased. When the precipitation time was 30 min, the maximum N content was 17.52 wt%. The increased of the N content is due to the enhance in vanadium content with the time accumulation. While exceeded 30 min, as water evaporates, other impurity ions such as  $SO_4^{2-}$  and  $Na^+$  were crystallized and mixed with the vanadium precipitation product.<sup>40</sup> The precursor has low purity, resulted a low N content in vanadium nitride. As shown in Fig. 3d, stirring rate can speed up the mass transfer process and make the reaction materials in a homogeneous system. Insufficient stirring rate, the distribution of various components is uneven and the crystal growth of the precursor is not complete. More impurities together with precipitation to form precursor because of the adsorption of C, which may reduce the purity of vanadium nitride and also make the N content lower. When the stirring speed too fast, intense mixing and shearing force destroy the precipitated crystal particles, increased surface area and adsorbed much impurities enter into precursor, resulted a decreased of the N content in the vanadium nitride. As a result, a drying time of 3.5 h, precipitation 30 min and stirring in 350 rpm was made sure as the best conditions.

**4.1.2 Effect of reduction and nitridation conditions on N content of vanadium nitride.** The precursor was prepared under the conditions about microwave power of 400 W, drying time of 3.5 h, vanadium precipitation time of 30 min and stirring rate of 350 rpm. Vanadium nitride was prepared by reduction nitridation of precursor and the effect of reaction temperature and  $N_2$  flow rate on the N content of vanadium nitride was investigated. The results are shown in Fig. 4.

It can be evidently observed from Fig. 4a that the reaction temperature has a marked effect on the N content in the vanadium nitride. The N content is only 10.21 wt% at 1000 °C. The temperature risen from 1100 °C to 1150 °C as well as the N content increased from 11.47 wt% to 17.65 wt%. When the temperature exceeded 1150 °C, the N content increased slightly, indicating that higher reaction temperature had little effect on the N content of the vanadium nitride. It can be looked into from Fig. 4b that the phases are  $V_3O_5$  and  $V_2O_3$  at 1000 °C. The phases are VN and  $V_2O_3$  at 1100 °C. When the temperature reached above 1150 °C, the phase is mainly VN. It indicated that the temperature is higher than 1150 °C, and the reduction and nitridation are fundamentally complete. Fig. 4c showed that the N content increased from 5.6 wt% to 17.67 wt%, and then dropped to 16.53 wt% as the  $N_2$  flow rate increased. The optimum flow rate of  $N_2$  was 200 ml min<sup>-1</sup> while the N content was 17.67 wt%. The phase analysis obtained with different nitrogen flow rates is shown in Fig. 4d. A flowing  $N_2$  can increased the partial pressure of  $N_2$  and decreased the partial





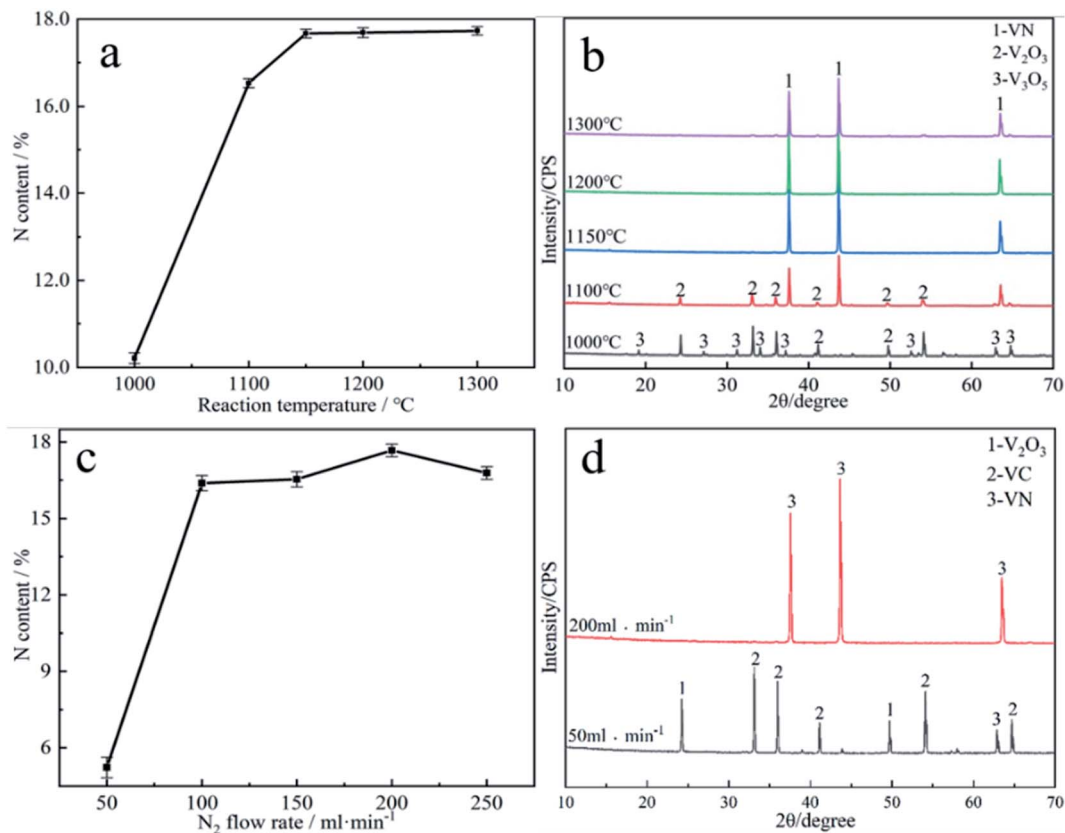


Fig. 4 Effect of reduction nitride conditions on the N content of vanadium nitride: (a) reaction temperature; (b) the physical phases of the products at each reaction temperature condition; (c) N<sub>2</sub> flow rate; (d) the physical phases of the products at different N<sub>2</sub> flow rate.

pressure of CO, thereby accelerating the reduction and nitridation reaction. The excessively fast of N<sub>2</sub> flow rate results in N<sub>2</sub> not being heated sufficiently, and the nitridation reaction cannot occur sufficiently during the fast flow, which leads to a decrease in N content. Therefore, 1150 °C and 200 ml min<sup>-1</sup> was confirmed as the optimal reaction conditions.

#### 4.2 Characterization of the precursor

Although the formation of vanadium nitride can be promoted by preparing precursor.<sup>29,30</sup> However, in this study, a precursor with uniform particle size and porous surface morphology was used to prepare vanadium nitride, a fact we consider an essential difference. Therefore, we had to investigate this precursor. To understand the comparison of the precursor phase composition, and XRD analysis was performed, the results are demonstrated in Fig. 5. The phase of the product obtained by direct vanadium precipitation, the precursor obtained by adding C for vanadium precipitation and the precursor obtained by microwave-assisted were analyzed. There was no change about the phase, and both are composed of (NH<sub>4</sub>)<sub>2</sub>V<sub>6</sub>O<sub>16</sub>·1.5H<sub>2</sub>O and (NH<sub>4</sub>)Al(SO<sub>4</sub>)<sub>2</sub>·12H<sub>2</sub>O. At the same time, the precursor obtained by microwave-assisted has sharper peaks, and the product crystallinity degree is higher. The C peak was not detected in the precursor was affiliated because of the amorphous state of C.

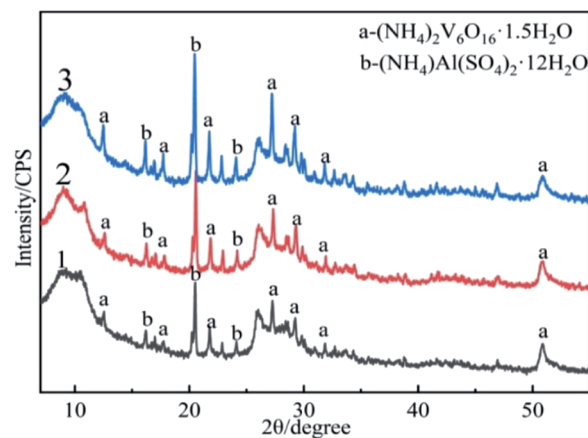


Fig. 5 XRD patterns of the precursor: (1) the product precipitated directly from vanadium solution; (2) the precursor obtained by vanadium precipitation with adding C; (3) the precursor obtained by microwave-assisted.

SEM-EDS was used to observe the microscopy of precursor, the results are shown in Fig. 6. The precursor obtained by vanadium precipitation with adding C were agglomerated and with a large particle size. After microwave-assisted, the precursor showed a good dispersion, uniform and small particle size. The structure exhibited appear porous structure in

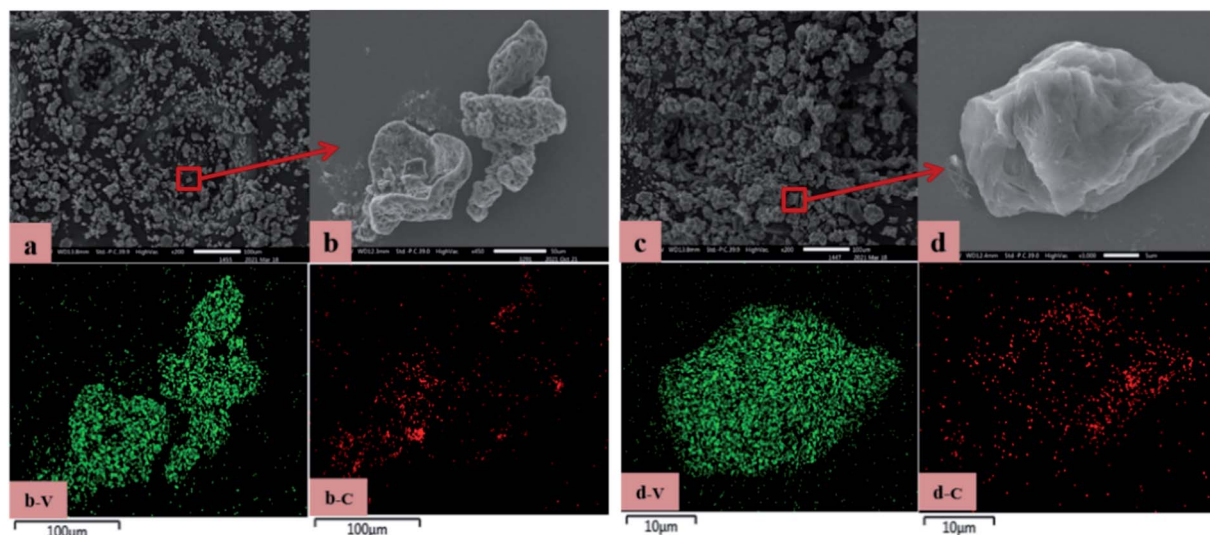


Fig. 6 SEM-EDS: (a) the precursor obtained by microwave-assisted; (b) the partially enlarged view of the edge of the precursor obtained by microwave-assisted; (c) the precursor obtained by vanadium precipitation with adding C; (d) the partially enlarged view of the edge of the precursor obtained by vanadium precipitation with adding C.

addition to the layered structure. The contact area with  $N_2$  have increased. At the same time, the residual water in the precursor evaporated during the reaction process, forming a large number of pores. The  $N_2$  is more likely to enter the material when it flowing rapidly, it can promote the formation of vanadium nitride.

The detection and analysis results of the particle size distribution was shown in Fig. 7. According to the particle size distribution diagram A, it can be seen that the precursor particles are normally distributed and both larger than 0.283  $\mu\text{m}$ . Compared the D10, D50, D90 of the two precursors in the diagram A, the particle size distribution width after microwave-assisted is more smaller. It could be seen that the particle size of the two precursor particles is  $d_{\text{microwave-assisted}} < d_{\text{without-microwave}}$ . It was discovered from diagram B that the cumulative

distribution range of the precursor prepared by microwave-assisted is mainly 10–40  $\mu\text{m}$ , and the content reached 77 wt% when the particle content without a microwave was only 66 wt%. After microwave-assisted, the precursor particles smaller than 10  $\mu\text{m}$  decreased by 4.46 wt%, and those larger than 30  $\mu\text{m}$  increased by 6.46 wt%. When the particle size is too small, vanadium and C do not form a package structure, the contact area decreased. When the particle size of is too large, the particle envelope formed with C as the nucleation point is too thick,<sup>29</sup> that C in the middle of the structure cannot be fully released to participate in the response, affecting the progress of the reaction. Therefore, the decreased and uniformity of precursor particle size is the mainly reason to promote the increase of N content.

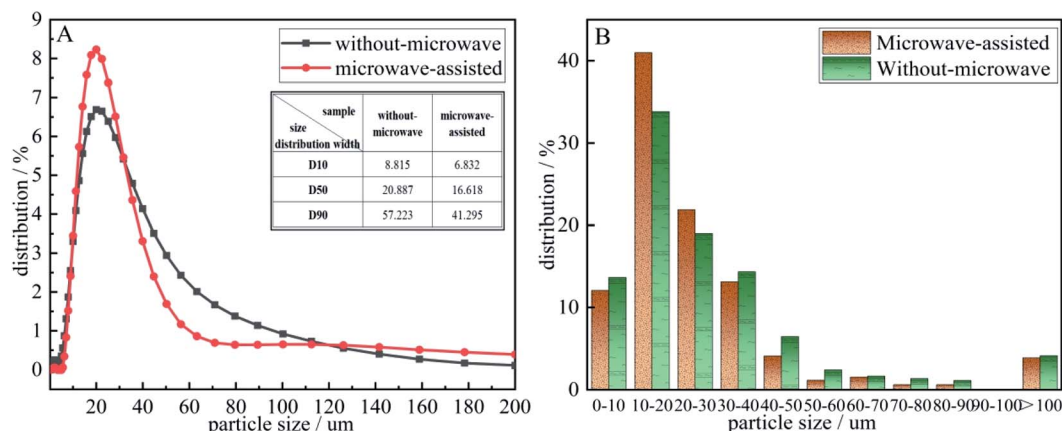
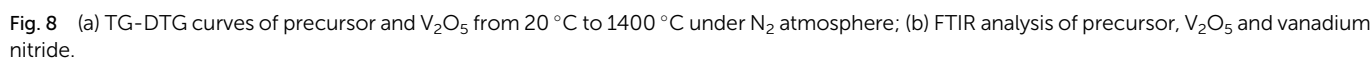


Fig. 7 The particle size distribution of the precursor (A): precursor particle size distribution diagram. (B) accumulative distribution of precursor grain size.



**Table 3** Comparison of reaction process of preparation of vanadium nitride from different vanadium sources

### 4.3 Characteristics of the precursor

From the FTIR curves in Fig. 8b, it can be seen that the  $\nu_{\text{O-H}}$  absorption peaks of  $\text{V}_2\text{O}_5$  and C as raw material are at  $476\text{ cm}^{-1}$ ,  $3435\text{ cm}^{-1}$ , provided by water of crystallization,  $\nu_{\text{V-O}}$  absorption peaks at  $582\text{ cm}^{-1}$ ,  $815\text{ cm}^{-1}$ ,  $1020\text{ cm}^{-1}$ , and H-O-H bond formation at  $1629\text{ cm}^{-1}$ , while the absorption characteristic peak of the precursor at  $1401\text{ cm}^{-1}$  is  $\nu_{\text{N-H}}$ , provided by the precursor  $1401\text{ cm}^{-1}$  in the precursor  $\text{NH}_4^+$  provided.<sup>42-44</sup>





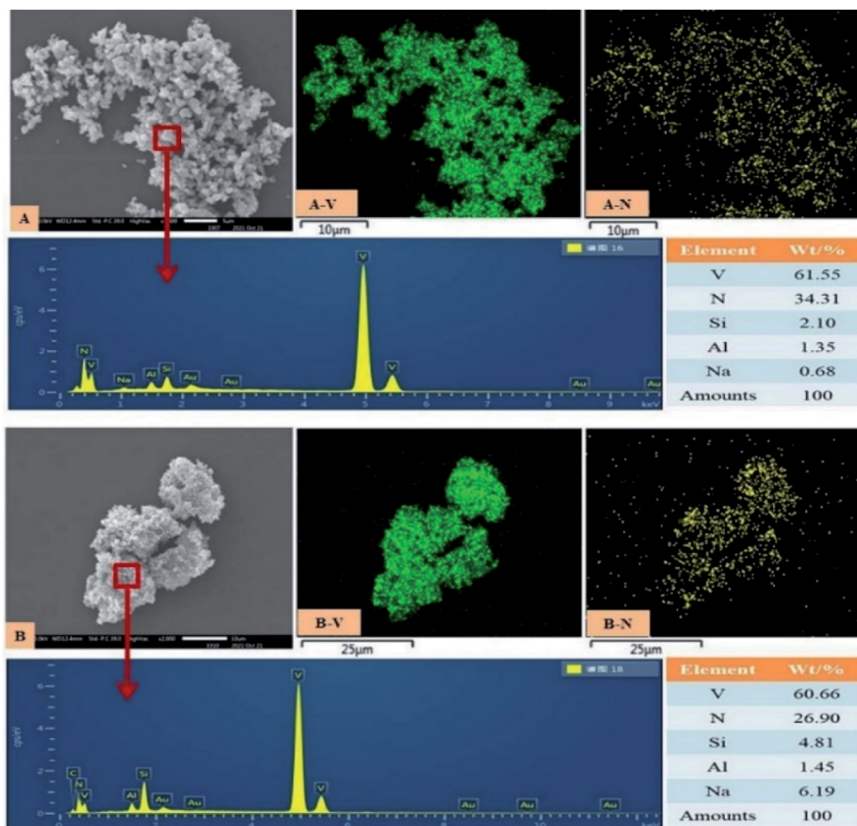


Fig. 10 SEM-EDS (A): vanadium nitride prepared by microwave-assisted in the precursor preparation; (B): vanadium nitride prepared without microwave in the precursor preparation.

Combined with the thermodynamic analysis and Fig. 8a TG-DTG, found  $\text{NH}_4^+$  is present in the form of  $\text{NH}_3$  during reductive nitration, which can facilitate the thermal decomposition process of the precursor. From the FTIR curves of vanadium nitride, it can be seen that  $\nu_{\text{V-N}}$  characteristic absorption peaks are formed at  $1050\text{ cm}^{-1}$  and  $1090\text{ cm}^{-1}$ .

A comparative analysis of the reaction process for the preparation of vanadium nitride from two different raw materials as vanadium sources is shown in Table 3.

The formation process of vanadium nitride after microwave-assisted preparation of the precursor is shown in Fig. 9. During the vanadium precipitation process, C was used as the nucleation point and  $(\text{NH}_4)_2\text{V}_6\text{O}_{16} \cdot 1.5\text{H}_2\text{O}$  in the slurry is adsorbed on C. With time increased, the precipitated particles increased and wrapped C. After the vanadium precipitation is completed, the precursor was prepared by filtering and drying. The precursor undergoes ammonia off, pre-reduction, reduction and nitridation to form vanadium nitride with an  $\text{N}_2$  atmosphere.

#### 4.4 Technical index of vanadium nitride

The microscopic observation of vanadium nitride was performed by SEM-EDS, the results are shown in Fig. 10. The vanadium nitrogen prepared by microwave-assisted had more structurally complete and consisted of homogeneous spherical particles. Area scans were carried out to check the distribution of the elements, it found a good correlation between V and N,

Table 4 Chemical composition of vanadium nitride (wt%)

V	N	C	P	S
79.32	17.67	2.11	0.058	0.10

with complete overlap between V and N regions. A point scan was performed and found that the V and N content increased and the impurity content decreased of the vanadium nitrogen produced after microwave-assisted. The chemical element content was shown in Table 4. The V content is 79.32 wt%, the N content is 17.67 wt%, the C content is 2.11 wt%, and the content of other impurity ions also meets the requirements of VN16. After the as-prepared product was briquetted under a pressure of 40 MPa, the measured density was  $3.10\text{ g cm}^{-3}$ . Can be used as an additive in steelmaking.

## 5 Conclusion

Microwave-assisted synthesis of precursor for the production of vanadium nitride is a feasible method. The precursor prepared under the conditions of microwave power of 400 W, drying time of 3.5 h, vanadium precipitation time of 30 min and stirring speed of 350 rpm, and then reduction and nitridation precursor under the conditions of the reaction temperature of  $1150\text{ }^\circ\text{C}$  and





N<sub>2</sub> flow rate of 200 ml min<sup>-1</sup> to production vanadium nitride. The vanadium nitride has good performance, and the content of various chemical components meets the requirements of VN16 in GB/T 20567-2020. The N content is 17.67 wt%, and V content is 79.32 wt%, which can be used as steel additives.

The NH<sub>3</sub> produced by the thermal decomposition of the precursor can be used as a reducing agent to reduce V<sub>2</sub>O<sub>5</sub> in N<sub>2</sub> atmosphere. The decomposition products of the precursor reduced by NH<sub>3</sub> may be V<sub>2</sub>O<sub>5</sub>, V<sub>3</sub>O<sub>5</sub>, V<sub>3</sub>O<sub>7</sub>, V<sub>4</sub>O<sub>9</sub>, V<sub>6</sub>O<sub>13</sub>, V<sub>2</sub>O<sub>4</sub>, V<sub>2</sub>O<sub>3</sub> and VO.  $\Delta G^0$  under standard conditions was analyzed and  $\Delta G^0 - T$  plots were plotted.

The mechanism of microwave-assisted synthesis of precursor promoting the formation of vanadium nitride was explained by XRD, SEM-EDS and particle size distribution changed about precursor. The particle size of the precursor prepared after microwave-assisted is reduced, which effectively shorten the N<sub>2</sub> diffusion path, and nitrogen can more easily penetrate into the material, improving the conversion efficiency of the internal raw material. At the same time, the specific surface area increased, and the reaction interface increased, which promoted the reaction.

## Conflicts of interest

There are no conflicts to declare.

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